# Piezoelectric characterization and thermal stability of a high-performance $\alpha$ -quartz-type material, gallium arsenate

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Piezoelectric measurements were performed on large single crystals (8 mm along the c direction) of an  $\alpha$ -quartz-type piezoelectric material, gallium arsenate, GaAsO<sub>4</sub>, which allow us to extend the structure-property relationships in the  $\alpha$ -quartz-type materials. These first measurements on Y-rotated-cut plates have shown that gallium arsenate is the highest-performance piezoelectric material of this group. As compared to the coupling coefficients of the other materials with the same structure  $(k_{SiO_2}=8\%, k_{AlPO_4}=11\%, \text{ and } k_{GaPO_4}=16\%)$ , gallium arsenate exhibits the highest piezoelectric coupling coefficient of about 22%, as has been predicted by the structure-property relationships. Moreover, from these piezoelectric measurements, the  $C'_{66}$  elastic constant was determined and compared with elastic constants in quartz-type materials. The proposed value for the cut angle of the AT plane in GaAsO<sub>4</sub> is -6.3°. In order to extend the previous thermal stability results, thermal gravimetric analysis (TGA) and x-ray diffraction have been carried out on GaAsO4 powder at high temperatures. It has been shown that GaAsO4 is stable up to 1030 °C. The thermal-expansion coefficient of GaAsO<sub>4</sub> is  $4.0 \times 10^{-5}$  K<sup>-1</sup>. The thermal expansion of the predicted AT plane  $(Y-6.3^{\circ})$  in GaAsO<sub>4</sub> is shown to be similar to that of the other materials. Finally, it is demonstrated that the intertetrahedral bridging angle  $\theta$  (A-O-B) of GaAsO<sub>4</sub> is the most stable in  $\alpha$ -quartz materials, which enables one to predict that GaAsO<sub>4</sub> should retain high piezoelectric performances up to 925 °C. © 2005 American Institute of Physics. [DOI: 10.1063/1.1874293]

# I. INTRODUCTION

Over the past decades, many studies have been carried out to develop piezoelectric materials,  $^{1-10}$  with better properties than those of the most used material,  $\alpha$  quartz. The candidate materials are principally  $AO_2$  and  $ABO_4$  (A=Si, Ge, Al, Ga and B=P, As) compounds. All these materials crystallize in the  $P3_121$  (or  $P3_221$ ) space group with three formula units per cell. The structure type adopted by  $ABO_4$  compounds is a cation-ordered derivative of the  $\alpha$ -quartz-type structure with a doubled c parameter with respect to that of the  $AO_2$ -type materials.

Structure-property relationships have been developed for these materials. The evolution of various physical, elastic, thermal, dielectric, and piezoelectric properties has been determined in terms of the crystal structure of the various compounds. In the case of  $\alpha$  quartz, the piezoelectric properties degrade beginning above 300 °C, well before the  $\alpha$ - $\beta$  transition at 573 °C. The contrast, based on these relationships, the most distorted structures could be expected to give rise to the highest-performance materials. Indeed, the most

distorted materials, such as  $\text{GeO}_2$  and  $\text{GaAsO}_4$ , for which the intertetrahedral A–O–B bridging angle  $\theta$  and the tilt angle  $\delta$  (tetrahedral tilt angle with respect to the  $\beta$ -quartz structure) are, respectively,  $130^\circ$  and  $25.7^\circ$  for  $\text{GeO}_2$  and  $129.6^\circ$  and  $26.9^\circ$  for  $\text{GaAsO}_4$  are predicted to exhibit a high piezoelectric coupling coefficient (k=22%) and to have a very high degree of thermal stability.  $^{13}$ 

Large single crystals of GaAsO<sub>4</sub> (8 mm along c axis) have been synthesized by hydrothermal methods. X and Z plates were prepared in order to measure dielectric constants  $\varepsilon'_{11}$  and  $\varepsilon'_{33}$ . The obtained values ( $\varepsilon'_{11}$ =8.5 and  $\varepsilon'_{33}$ =8.6) are the highest measured for  $\alpha$ -quartz-type materials. The linear variation sestablished between  $\varepsilon'_{11}$  and the coupling coefficient k can be used to predict the high piezoelectric properties for GaAsO<sub>4</sub> and particularly a coupling coefficient of about 22%. Up to now, no piezoelectric measurements have been performed on this material.

In the first part of this paper, the results obtained on *Y*-rotated cut crystals are presented. The cut angle is very close to the value predicted from structure-property relationships. The structural quality was checked by x-ray topographic methods and piezoelectric measurements were performed on these *Y*-rotated plates. The first piezoelectric

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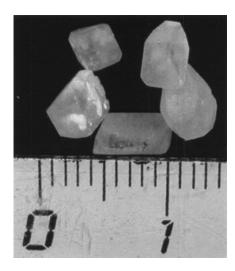


FIG. 1. GaAsO<sub>4</sub> single crystals.

measurements on  $GaAsO_4$  are presented and the results are used to extend the structure-property relationships in  $\alpha$ -quartz-type materials. In the second part, the thermal stability of  $GaAsO_4$  is investigated *in situ* by thermal gravimetric analysis (TGA) and x-ray diffraction on powder samples. Finally,  $\alpha$ -quartz-type materials are compared in terms of piezoelectric properties and thermal stability to define their field of application.

# **II. EXPERIMENT**

Gallium arsenate crystals and powder were prepared by a hydrothermal method in a polytetrafluorethylene (PTFE)-lined autoclave as described previously. <sup>18</sup> The faces of a selected crystal were indexed by x-ray diffraction using an Enraf-Nonius CAD4 diffractometer. The crystal was cut with a Well 4240 single-wire saw. The geometry of the crystal leads us to study only one direction, a *Y*-rotated cut (belonging to the IEEE orthogonal references <sup>19</sup>). The cut angle was checked by x-ray diffraction with the diffractometer described above. In order to improve the piezoelectric response of the samples, the thickness of the plates was reduced by polishing.

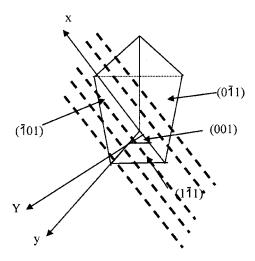


FIG. 2. Orientation of the Y-rotated-cut plates.

X-ray topography was used to check the structural quality of the GaAsO<sub>4</sub> crystal. This method corresponds to a Laue experiment. Due to the very high x-ray absorption of GaAsO<sub>4</sub>, synchrotron radiation of DCI ring (LURE, Orsay) was used. Each lattice plane is in diffraction condition for one wavelength and its harmonics in the white spectrum, which allows us to obtain one image of the crystal for each diffraction vector. Dark contrasts on the obtained photo are due to structural defects such as dislocations, twins, or inclusions.

Piezoelectric measurements were performed by the airgap method with nonadherent electrodes on the plates. The air-gap setup used for these measurements<sup>20</sup> can provide air gaps varying from zero to several tens of microns with an absolute accuracy and a reproducibility of 1 or 2  $\mu$ m. Gaps smaller than this can also be obtained by detecting the contact of the probe with the sample based on the onset of a larger attenuation and the change of the response. In the present study, as small gaps as possible (a few microns) have been chosen while avoiding the contact between the probe and the sample. The upper electrode was a 5-mm-diameter rod of Invar with a polished flat face and the lower electrode a gold thin film deposited on a flat piece of polished silica. A Hewlett-Packard (HP) network analyzer was used to measure the piezoelectric performances (resonance Fr and antiresonance Fa frequencies and coupling coefficient k). The thickness of the plates was measured by a micrometer with an accuracy of  $\pm 1 \, \mu \text{m}$ .

In order to investigate the thermal stability of GaAsO<sub>4</sub>, TGA was performed up to 1250 °C using a Setaram Labsys instrument. 190.1 mg of GaAsO<sub>4</sub> powder were introduced into a platinum crucible. The heating rate was 5°/mn. The signal of the crucible was subtracted from the experimental results.

High-temperature x-ray powder-diffraction measurements were performed on a PANanalytical X'Pert diffractometer equipped with an X'Celerator detector using Ni-filtered, Cu K $\alpha$  radiation. GaAsO<sub>4</sub> powder, which had been ground and passed through a 20- $\mu$ m sieve followed by annealing at 800 °C (to eliminate the hydrated compounds eventually present in the powder), was placed in the sample holder of an Anton Paar HTK 1200 high-temperature oven chamber. X-ray diffraction data were obtained over the 19°–

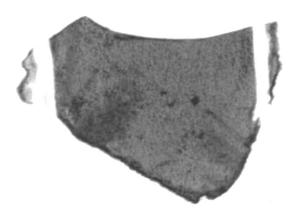


FIG. 3. X-ray topography of a Y-rotated plate of GaAsO<sub>4</sub>. (The two white bars at the extremities of the sample are due to the supports.)

TABLE I. Air-gap piezoelectric results.

Third or fifth overtone Fundamental mode (MHz) (MHz)		Overtone order $(n)$	k (%)	Wave velocity (m/s)	C' <sub>66</sub> (GPa)
Sample1					
(d=0.195  mm)					
16.690 39	5.435 84	3.0704	25.65	2176	18.8
16.691 46	5.435 84	3.0706	25.69	2176	18.8
16.690 39	5.460	3.0568	23.02	2175	19.0
16.691 46	5.460	3.057	23.06	2175	19.0
Sample2					
(d=0.194  mm)					
16.833 62	5.519 65	3.0498	21.53	2182	19.2
16.834 57	5.519 65	3.0499	21.57	2182	19.2
16.833 62	5.533 01	3.0424	19.86	2181	19.4
16.834 57	5.533 01	3.0426	19.90	2181	19.4
16.833 62	5.552 47	3.0317	17.17	2180	19.5
16.834 57	5.552 47	3.0319	17.22	2180	19.5
28.009 06	5.519 65	5.0744	19.62	2175	19.3
28.0018	5.519 65	5.0731	19.45	2174	19.3
28.009 06	5.533 01	5.0622	17.93	2175	19.4
28.0018	5.533 01	5.0609	17.74	2174	19.4
Sample3					
(d=0.189  mm)					
17.062 25	5.611 61	3.0405	19.42	2153	18.9
17.065 06	5.611 61	3.041	19.54	2154	18.9
17.068 01	5.611 61	3.0416	19.66	2154	18.9
Average			20.47	2173	19.2

124° range in  $2\theta$  over the temperature range up to 925 °C. Acquisition times were approximately 3 h. Rietveld refinements were performed with the program FULLPROF. <sup>21</sup> Due to the relatively low scattering factor of oxygen, soft constraints were applied to the Ga–O and As–O distances.

## **III. RESULTS AND DISCUSSION**

## A. Y-rotated cut plates

After growing  $GaAsO_4$  crystals, <sup>18</sup> their faces were indexed by x-ray diffraction (Fig. 1) and Y-rotated-cut plates were sawn (Fig. 2). A Y-rotated cut is a plate whose surface is parallel to the crystallographic x axis and produces an angle (termed cut angle) with the z axis. Structure-property relationships<sup>22</sup> show that the angle for an AT cut (athermal cut: lowest variation of the resonance frequency with tem-

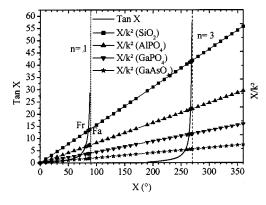


FIG. 4. Graphical resolution of  $\tan X = X/k^2$  with  $X = n\pi\omega_r/2\omega_a$  for the four well-known  $\alpha$ -quartz-type materials.

perature) for  $GaAsO_4$  should be  $-5^\circ$ . This value was selected to cut the crystal. After cutting, the orientation of the plates was checked by x-ray diffraction. The plane of the plates is  $(0\overline{4}1)$ , which corresponds to a cut angle of  $-6.26^\circ$  which is in the same range as the target value of  $-5^\circ$ .

X-ray topography (Fig. 3) of the plates indicates the high structural quality of the raw material that is necessary to undertake very accurate piezoelectric measurements. Only a few contrasts indicate the presence of certain defects. The black point in the middle of the photo probably corresponds to a solvent inclusion. The general aspect of the plate is due to the surface state of the plate which is not of optical quality.

#### B. Piezoelectric characterizations

#### 1. Air-gap measurements

In the air-gap measurements, complex responses were observed for the fundamental mode for nearly all the samples, which display many resonances between the expected resonance frequency of the thickness shear mode and a frequency slightly above the expected antiresonance frequency. This kind of response is due to the coupling of the thickness shear with several plate modes most probably due to the boundary conditions at the edge of the plate. The response for the third overtone was generally more conventional with less modes and often several resonances very close to the strongest. The fifth overtone was generally weak with one or two resonances. No resonance that can be definitively assigned to the seventh overtone was observed in any sample. The first resonance frequencies observed for two samples are given in Table I. In this table, the results given

Material	SiO <sub>2</sub> (Ref. 32)	AlPO <sub>4</sub> (Ref. 5)	GaPO <sub>4</sub> (Refs. 33and34)	GaAsO <sub>4</sub>
AT-cut angle (°)	-35.15	-33.02	-15.9	-6.3
Cristallographic plane for AT cut	$(0\overline{1}2)$	$(0\overline{4}7)$	$(0\overline{4}3)$	$(0\overline{4}1)$
A-O- $B$ angle (°)	143.2	142.4	134.2	129.6
Coupling coefficient $k$ (%)	8	11	16	21-23
$C_{66}$ (GPa)	40	29.4	22.38	
$C_{11}$ (GPa)	86.79	69.3	66.58	
$C_{12}$ (GPa)	6.79	10.5	21.81	
$C_{13}$ (GPa)	12.01	13.5	24.87	
$C_{33}$ (GPa)	105.79	88.6	102.1	
$C_{44}$ (GPa)	58.21	43	37.66	
$C_{14}$ (GPa)	18.12	13	3.91	
$C_{66}$ (GPa)	28.9	21.6	21.3	19.2
Density (g/cm <sup>3</sup> )	2.64	2.63	3.57	4.23
AT-cut wave velocity (m/s)	3307	2863	2442	2173

TABLE II. AT-cut characteristic parameters of the well-characterized  $\alpha$ -quartz materials compared to the corresponding experimental values obtained for GaAsO4.

for the samples 1 and 2 were obtained with the same plate (as polished for the sample 1, and slightly etched for the sample 2).

The calculations were made using the one-dimensional model for thickness shear.<sup>23,24</sup> This model, in which in the present case one thickness mode is excited, leads to the following expression of the electrical impedance of the resonator:

$$Z(\omega_r) = \frac{1}{j\omega_r C_0} \left( 1 - k^2 \frac{\tan X}{X} \right) \text{ with } X = \frac{n\pi\omega_r}{2\omega_a}, \tag{1}$$

where k is the coupling coefficient of the mode,  $C_0$  the static capacity,  $\omega_r$  is the resonance frequency of the *n*th overtone,  $\omega_a$  is the antiresonance frequency of the *n*th overtone, and *n* is the order of the overtone (n is an odd number).

At any resonance frequency of any (n):  $Z(\omega_r)=0$  and  $\tan X=X/k^2$ 

$$X = \frac{n\pi\omega_r}{2\omega_a} = \frac{\omega_r d}{2V} \quad \text{with } V = \omega_a \frac{d}{n\pi} = \sqrt{\frac{\overline{C}}{\rho}}$$
 (2)

and

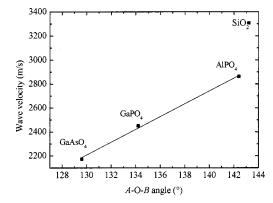


FIG. 5. Wave velocity of the shear mode vibration (associated with the  $C'_{66}$ elastic constant) of the AT cut in the  $\alpha$ -quartz materials.

$$\omega_a = \omega_r \left( \frac{4k^2}{n^2 \pi^2} + 1 \right),\tag{3}$$

where V is the wave velocity, d the thickness of the plate, and  $\rho$  the density (4.23 g/cm<sup>3</sup> for GaAsO<sub>4</sub>).

 $\overline{C}$  is the stiffened elastic constant of the shear mode. In order to take into account the piezoelectric effect, a correction<sup>25</sup> has to be applied using the following equation:

$$C = \overline{C}(1 - k^2). \tag{4}$$

After this correction, the elastic constant C (element of the Christoffel matrix) refers to constant D and is comparable to the value obtained by conventional methods such as Brillouin scattering or pulse echo measurements.

The principle of the calculation is to take for each sample one resonance of an overtone (n) and one resonance of the fundamental mode to compute the ratio of their frequencies. For the "true" thickness shear mode, this ratio should be greater than n due to the properties of the roots of the  $Z(\omega)=0$  equation (since k<1). If this is the case, with graphical resolution (Fig. 4) and considering the previous equations it is possible to solve simultaneously the  $Z(\omega)=0$ equation for the two modes and extract the coupling coefficient k, the wave velocity V, and consequently the elastic

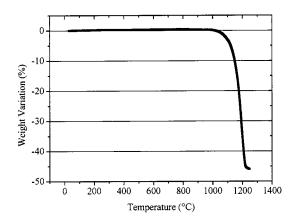


FIG. 6. TGA measurements on GaAsO<sub>4</sub> powder.

TABLE III. Unit-cell parameters, volume, and agreement factors for GaAsO<sub>4</sub> as a function of temperature.

T (°C)	a (Å)	c (Å)	$V(\mathring{A}^3)$	Rp	Rwp	$R_B$
25	4.997(1)	11.386(1)	246.2(1)	30.7	17.3	9.98
200	5.011(1)	11.393(1)	247.7(1)	32.1	17.5	11.4
400	5.029(1)	11.402(1)	249.7(1)	32.9	17.4	10.7
600	5.047(1)	11.411(1)	251.7(1)	33.2	17.0	10.5
800	5.065(1)	11.419(1)	253.7(1)	34.6	17.3	10.1
850	5.069(1)	11.421(1)	254.2(1)	36.1	17.6	11.1
925	5.077(1)	11.425(1)	255.0(1)	36.2	17.5	10.9

constant  $\overline{C}$  of the considered thickness shear mode. It can be observed on Fig. 4 that the gap between Fr and Fa increases with high electromechanically coupled materials such as  $GaAsO_4$ . This property is often required for large band piezoelectric filters, for example. The elastic constants measured under piezoelectric excitation are corrected as above. In the present case, the samples are *Y*-rotated cuts for which the elastic constant termed  $C'_{66}$  is calculated from the previous Eqs. (2) and (4) and is related to the cut angle  $\theta$  by the following relationship:

$$C'_{66} = C_{44} \sin^2 \theta + C_{66} \cos^2 \theta + 2C_{14} \cos \theta \sin \theta.$$
 (5)

These calculations were performed for all measured modes near the expected fundamental resonance of the thickness shear mode and of its overtones (Table I). These results indicate that gallium arsenate has the highest coupling coefficient among all known quartz analogs and the lowest wave velocity. Some scatter is observed certainly due to differences in the material (impurities or solvent inclusions) of these samples. The lowest values tend to underestimate the average coupling coefficient, whose value can reach 22% or 23%.

The average values show, from the point of view of piezoelectric properties, that  $GaAsO_4$ , as was predicted, is a promising material with a high coupling coefficient. It must be noted that these first measurements have been made using the air-gap method. Thus, the piezoelectric values and particularly the Q value (quality factor) can be increased by manufacturing conventional resonators with adherent thin-film electrodes. The  $C_{66}'$  value obtained from the present measurements is  $19.2\pm0.2$  GPa.

# 2. Comparison to the other $\alpha$ -quartz-type materials

In previous studies, 11-16 many authors have established different relationships between the structural distortion and

the piezoelectric properties in  $\alpha$ -quartz-type materials. Based on these results, it was predicted that GaAsO<sub>4</sub> should be an excellent piezoelectric material<sup>22</sup> with high coupling coefficient (22%) for an AT-cut angle near  $-5^{\circ}$ . These first experimental results on  $Y-6.3^{\circ}$ -rotated cut confirm this prediction. The coupling coefficient of GaAsO<sub>4</sub> is found to be almost 50% greater than that of GaPO<sub>4</sub> (Table II), until now the most highly coupled material of this material family.

From the elastic constants and the well-known AT-cut angle  $\theta$  of the  $\alpha$ -quartz materials,  $C_{66}'$  values are determined and the wave velocity of the AT cut is compared to the experimental value found in the case of GaAsO<sub>4</sub> (Table II). If it is reasonable to consider a linear variation of the wave velocity values in terms of distortion in the  $ABO_4$  materials (Fig. 5), the experimental value of 2173 m/s fits very well, which confirms the value of 19.2 GPa for the  $C_{66}'$  constant of GaAsO<sub>4</sub>. Moreover, this result confirms that the AT-cut angle should be near this experimental value of  $-6.3^{\circ}$ . It must be noted that  $AO_2$  materials (i.e., SiO<sub>2</sub>) are not included in this linear variation because this type of material is built up of only one type of tetrahedron  $AO_4$ .

#### C. Thermal behavior

#### 1. Thermal analysis

TGA results (Fig. 6) up to 1250 °C indicate the beginning of the weight loss at 1030 °C which reaches 46% at the end of the run. This weight loss corresponds to the thermal decomposition of GaAsO<sub>4</sub> following the reaction:

$$2GaAsO_4 \rightarrow Ga_2O_3 + As_2O_5$$
.

X-ray diffraction measurements performed on a powder before and after TGA analysis confirm this reaction. No presence of  $As_2O_5$  is found in the recovered  $Ga_2O_3$  compound because  $As_2O_5$  is not stable and sublimes at 315 °C. <sup>26,27</sup>

TABLE IV. Fractional atomic coordinates and isotropic atomic displacement parameters ( $\mathring{A}^2$ ) of GaAsO<sub>4</sub> as a function of temperature. Trigonal:  $P3_121\ Z=3$ , Ga: 3a sites (x,0,1/3), As: 3b sites (x,0,5/6), O: 6c sites (x,y,z).

T (°C)	x (Ga)	x (As)	B <sub>iso</sub> (Ga,As)	$x(O_1)$	$y(O_1)$	$z(O_1)$	$x(O_2)$	$y(O_2)$	$z(O_2)$	$B_{\rm iso}({\rm O}_1,{\rm O}_2)$
25	0.4519(1)	0.4520(2)	2.50(2)	0.3855(12)	0.3043(14)	0.3888(5)	0.4027(17)	0.2926(13)	0.8729(4)	3.30(13)
200	0.4528(1)	0.4543(2)	3.06(3)	0.3835(15)	0.3010(14)	0.3893(5)	0.4015(16)	0.2889(13)	0.8740(4)	2.97(13)
400	0.4541(1)	0.4563(2)	3.51(3)	0.3822(14)	0.2975(13)	0.3900(5)	0.3961(15)	0.2817(13)	0.8761(4)	3.52(13)
600	0.4550(1)	0.4578(2)	3.75(3)	0.3838(14)	0.2967(13)	0.3900(5)	0.4039(16)	0.2854(13)	0.8750(4)	4.26(14)
800	0.4556(1)	0.4590(2)	4.03(3)	0.3877(16)	0.2982(14)	0.3893(5)	0.4007(16)	0.2805(13)	0.8767(4)	4.45(14)
850	0.4559(1)	0.4589(2)	3.97(3)	0.3935(18)	0.3027(16)	0.3880(6)	0.4034(19)	0.2830(15)	0.8760(5)	5.77(16)
925	0.4552(1)	0.4584(2)	4.22(3)	0.3888(16)	0.2980(14)	0.3898(5)	0.4019(16)	0.2807(13)	0.8771(4)	5.26(15)

Ga–O–As $_{\rm average}$  (°) T (°C) Ga-O<sub>1</sub>-As (°) Ga-O2-As (°)  $\delta_{av}$ GaO<sub>4</sub>  $\delta_{av} AsO_4$  $\delta_{\rm av}$ 25 130.5(3) 130.4(3) 130.4(3) 23.1(4)27.5(4)25.3(4)200 130.6(3) 131.0(3) 130.8(3) 22.6(4)26.9(4)24.8(4)22.0(4)400 130.9(3) 131.5(3) 131.2(1) 26.0(4)24.0(4)600 131.4(3) 132.2(3) 131.8(3) 21.8(4)26.1(4)24.0(4)800 131.9(3) 132.8(3) 132.4(3) 21.7(4)25.4(4)23.6(4)22.2(5)850 132.2(4) 132.8(3)132.5(4)25.6(5)23.9(5)

132.8(3)

21.5(4)

133.3(3)

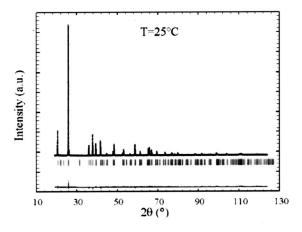
TABLE V. Intertetrahedral Ga-O-As bridging and tetrahedral tilt angles ( $^{\circ}$ ) in GaAsO<sub>4</sub> as a function of temperature.

#### 2. X-ray diffraction at high temperatures

925

a. Structural stability. The structural refinements for temperatures up to 925 °C (Tables III-V) are in good agreement with and complement the previous single-crystal x-ray diffraction studies up to 800 °C. 13 Very good agreement was obtained between experimental and calculated profiles (Fig. 7). The present values indicate that the Ga-O-As intertetrahedral bridging angles are very stable (Fig. 8) in comparison with those of other materials. The slope of the curve integrated up to 400 °C is the lowest for GaAsO<sub>4</sub> (2.1  $\times 10^{-3}$  °/K) in comparison with quartz (7.4×10<sup>-3</sup> °/K),  $(8.7 \times 10^{-3} \, ^{\circ}/\mathrm{K}),$ berlinite and even GaPO<sub>4</sub> (5.2  $\times 10^{-3}$  °/K). Thus, GaAsO<sub>4</sub> is the most thermally stable  $\alpha$ -quartz material. Moreover, the variation of Ga–O–As in-

132.4(3)



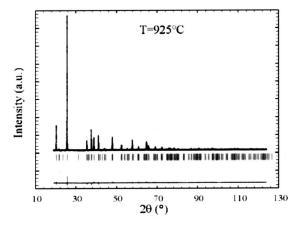


FIG. 7. Experimental (+) and calculated (solid line) powder-diffraction profiles from the Rietveld refinements of the structure of GaAsO<sub>4</sub>. The lower curve is the difference curve between experimental and calculated profiles.

tertetrahedral bridging angles is linear up to 925 °C, whereas the corresponding variation is linear only up to 800 °C for GaPO<sub>4</sub>. This behavior leads us to conclude that the piezoelectric properties of GaAsO<sub>4</sub> should be stable up to at least 925 °C, whereas the piezoelectric properties of GaPO<sub>4</sub> degrade beginning at 800 °C.<sup>28</sup> Thus, for GaAsO<sub>4</sub> resonators, it is probably possible to increase the useful temperature range by at least 125° compared to GaPO<sub>4</sub>.

25.2(4)

23.3(4)

b. Thermal expansion. The temperature dependence of the cell volume was fitted with a linear function and the thermal volume expansion coefficient of GaAsO<sub>4</sub> normalized at 298 K is found to be  $\alpha_{v(298~\text{K})}=4.0\times10^{-5}~\text{K}^{-1}$ . This value is in the same range as that of quartz, <sup>29,30</sup> or berlinite. <sup>31</sup> As for the other  $\alpha$ -quartz materials, there is a preferential expansion along the  $\alpha$  axis:  $\alpha_{a(298~\text{K})}=1.78\times10^{-5}$  and  $\alpha_{c(298~\text{K})}=3.78\times10^{-6}$ .

It is proposed, based on the above piezoelectric results, to assign the AT-cut plane to the  $(0\overline{4}1)$  plane for which the interplanar distance d can be calculated from the x-ray diffraction data. It is thus possible to estimate the thermal expansion of the AT plane. By comparing the  $d_{(AT\ cut)}$  at different temperatures relative to the value at room temperature, it is possible to determine the thermal-expansion coefficient for the AT plane for each material (Fig. 9). Quartz and berlinite exhibit important variations in the interplanar distance of the AT plane above 400 °C due to the  $\alpha$ - $\beta$  transition. Linear regressions of  $d_{(AT\ cut)}$  as a function of temperature (T< 400 °C) permit the materials to be compared. GaAsO<sub>4</sub> presents an AT-plane thermal-expansion coefficient of

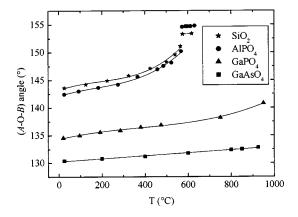


FIG. 8. Temperature dependence of the intertetrahedral (A–O–B) bridging angle in  $\alpha$ -quartz materials (see Refs. 29, 31, 35, and 36).

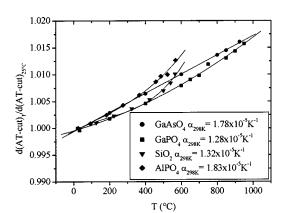


FIG. 9. Evolution of the normalized interplanar distance of the AT plane as a function of the temperature for the well-characterized  $\alpha$ -quartz materials (see Refs. 29, 31, and 36).

 $\alpha_{\rm AT(298~K)} = 1.78 \times 10^{-5}~{\rm K}^{-1}$ , which is the same as those of the x (or y) axis (confirmation of the cut angle, which is close to the xz plane) and essentially identical to those of berlinite  $(1.83 \times 10^{-5}~{\rm K}^{-1})$ . GaPO<sub>4</sub> and quartz exhibit the lowest values of  $1.28 \times 10^{-5}$  and  $1.32 \times 10^{-5}~{\rm K}^{-1}$ , respectively.

#### **IV. CONCLUSION**

The first piezoelectric measurements on gallium arsenate have been performed on (Y 6.3°)-rotated-cut plates obtained from large single crystals grown by hydrothermal methods. X-ray topography indicates that the crystal is of high quality. The piezoelectric results indicate that the coupling coefficient (21.5%–23%) for the AT-cut angle is the highest among  $\alpha$ -quartz isotypes, thereby confirming previous extrapolations based on structure-property relationships. The experimental wave velocity (2173 m/s) confirms that the AT cut is close to  $-6.3^{\circ}$ . Concerning the thermal stability of GaAsO<sub>4</sub>, TGA results show that this compound decomposes into its constituent binary oxides above 1030 °C. Structure refinements using x-ray powder-diffraction data up to 925 °C confirm the very high stability of the fine structure of GaAsO<sub>4</sub>. Thus, GaAsO<sub>4</sub>-based resonators should work up to 925 °C (at least 125 °C higher than for GaPO<sub>4</sub>). Moreover, the ATcut angle has been confirmed by comparison of the thermal expansion of the AT-cut plane for the four well-characterized  $\alpha$ -quartz-type materials.

It has thus been shown experimentally that  $GaAsO_4$  exhibits the best piezoelectric properties and is the most thermally stable material in the  $\alpha$ -quartz group.

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